

**Performance characteristics:**

- Frequency band:DC~20GHz
- Noise factor:2dB
- Gain : 12dB
- Output P1dB:15dBm
- Output IP3:30dBm
- Power supply:+8V@70mA
- Chip size:3.12mm×1.38mm×0.1mm

**Product Description:**

The CW-LN460-G is a GaAs MMIC ultra wideband low-noise amplifier chip with a frequency range covering DC~20GHz and a typical noise figure of 2.0dB throughout the band. the CW-LN460-G is powered by +8V.

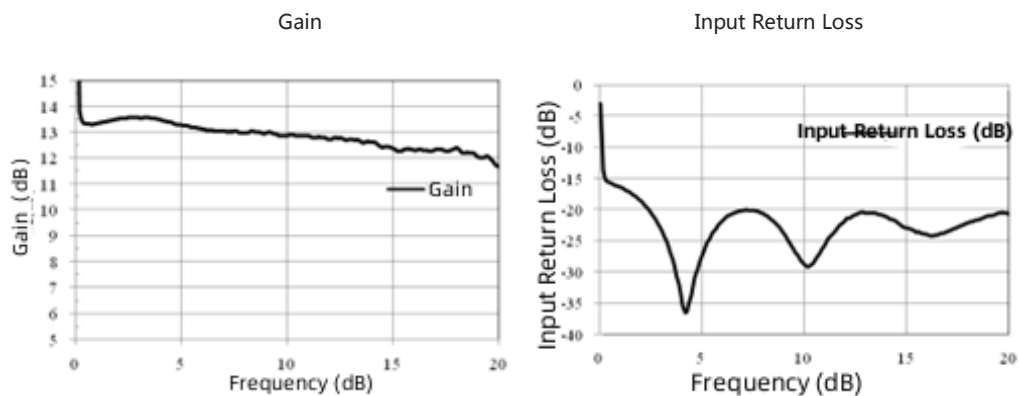
**Electrical parameters:**(  $T_A=25^{\circ}C$  ,  $V_D=+8V$  ,  $V_G=-0.74V$ )

Indicators	Minimum value	Typical values	Maximum value	Unit
Frequency range	DC~25			GHz
Noise factor	-	2	-	dB
Gain	-	12	-	dB
Input Return Loss	-	15	-	dB
Output Return Loss	-	15	-	Db
Output P-1dB	-	15	-	dBm

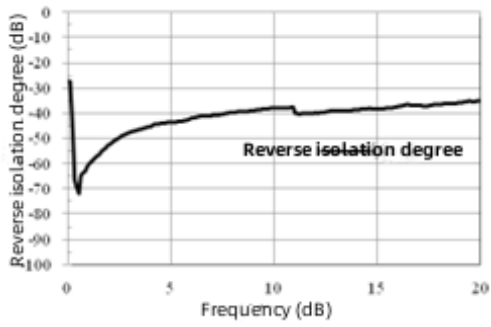
**Usage limitation parameters :** (Exceeding any of the above maximum limits may result in permanent damage.)

Input power	+23dBm
Control voltage	+9V
Storage temperature	-65°C~150°C
Operating temperature	-55°C~125°C

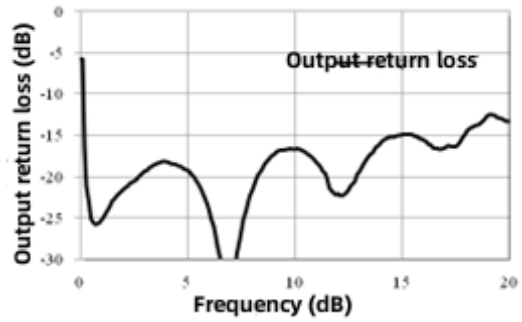
**Typical curves:**



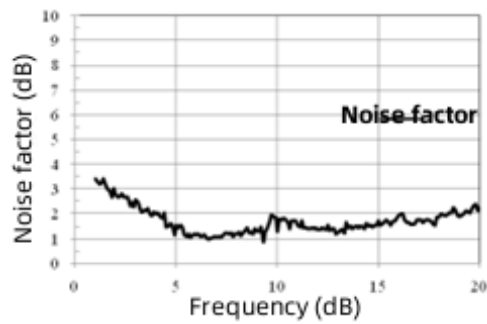
Reverse isolation degree



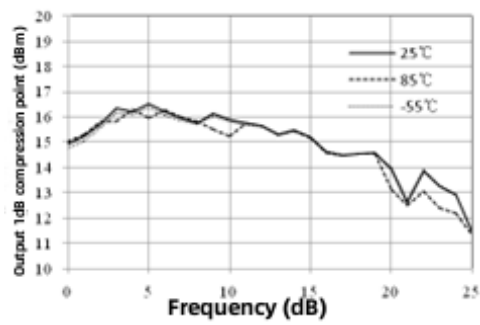
Output Return Loss



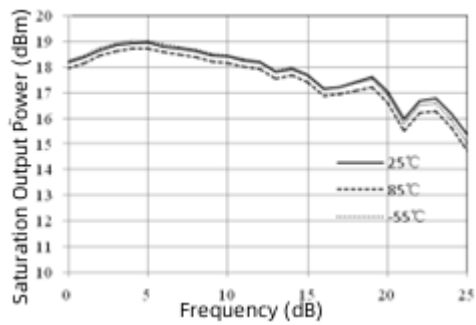
Noise factor Vs temperature



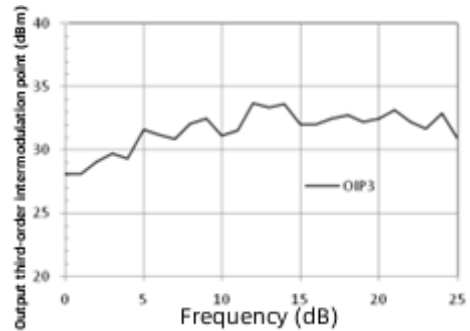
Output 1dB compression point Vs temperature



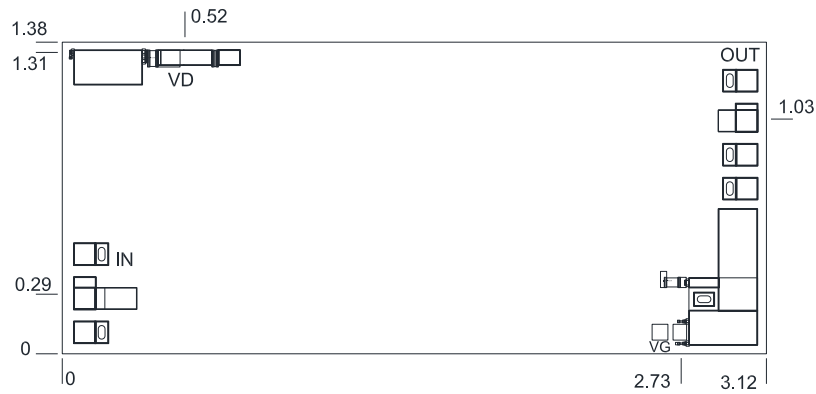
Output saturation power Vs Temperature



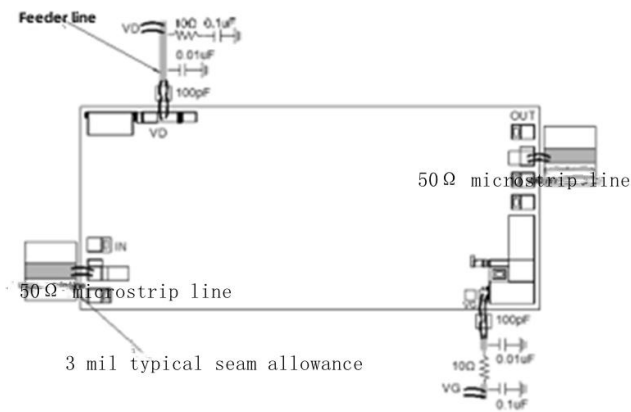
Output third-order intermodulation point (25°C)



**Dimensional drawing:** (unit mm)



**Suggested assembly drawing:**



**Instructions for use:**

**Caution:** Input and output have isolation capacitors

**Storage:** The chip must be placed in a container with electrostatic protection and stored in a nitrogen atmosphere.

**Cleaning treatment:** Bare chips must be operated and used in a purified environment, and it is prohibited to use liquid cleaners to clean the chips.

**Electrostatic protection:** Please strictly comply with ESD protection requirements to avoid electrostatic damage to the device.

**Routine operation:** Please use vacuum chuck or precision pointed tweezers to pick up the chips. Avoid touching the chip surface with tools or fingers during the operation.

**Mounting operation:** Chip mounting can be done using AuSn solder eutectic welding or conductive adhesive bonding process. The mounting surface must be clean and flat.

**Bonding operation:** 2 (25  $\mu$ m diameter gold wire is recommended) bonding wires for each input and output, with a bonding wire length of less than 250  $\mu$ m optimal. It is recommended to use the lowest possible ultrasonic energy. Bonding starts at the pressure point on the chip and ends at the package (or substrate).